Ferromagnetic resonance, transverse bias initial inverse susceptibility and torque studies of magnetic properties of Co$_2$MnSi thin films

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Abstract. Magnetic properties of Co$_2$MnSi thin films of 20 nm and 50 nm in thickness grown by radio frequency sputtering on a-plane sapphire substrates have been studied. X-ray diffraction (XRD) revealed that the cubic <110> Co$_2$MnSi axis is normal to the substrate and that well defined preferential in-plane orientations are present. The static magnetic properties were studied at room temperature by conventional magneto-optical Kerr effect (MOKE), transverse bias initial inverse susceptibility and torque (TBIIST) MOKE. The dynamic magnetic properties were investigated by micro-strip ferromagnetic resonance (MS-FMR) at room temperature. The resonance and TBIIST measurements versus the direction of the in-plane applied magnetic field reveal that the in-plane anisotropy results from the superposition of a two-fold and a four-fold symmetry. The directions of the principal axes of the twofold anisotropy are sample dependent. The angular dependence of remanent normalized magnetizations and coercive fields, studied by MOKE are analyzed within the frame of a coherent rotation model. A good agreement is observed between the field anisotropy values obtained from MS-FMR and from TBIIST data. Frequency and angular dependence of FMR linewidth has been studied. Apparent damping coefficient of 0.0112 has been measured for 50 nm thick sample.

1 Introduction

Cobalt-based full-Heusler with a general composition Co$_2$YZ (Y is element of the transition metal group, whereas the Z component comes from the group III-V elements) alloys are the most interesting class of Heusler materials for spintronic applications due to their predicted 100% spin-polarization and their high Curie temperature largely exceeding the room temperature. Moreover, the investigation of the magnetocrystalline anisotropies is a possible way to get insight of the spin-orbit interaction which would have a strong impact on the spin depolarization. Another technological interesting parameter is the Gilbert damping. Although low damping is essential for spin switching with low currents and spin torque oscillators, it enhances the spin-torque-induced magnetic noise in CPP GMR sensors.

The purpose of this paper is to use ferromagnetic resonance in microstrip line (MS-FMR) under an in-plane and out of plane applied magnetic field and combined transverse biased initial inverse susceptibility and torque (TBIIST) methods to study the magnetic properties of Co$_2$MnSi thin films. The TBIIST method surely does not have the same reputation of FMR techniques but seems to be complementary to FMR especially for samples showing weak signals non detectable by FMR methods. We will show that TBIIST is a powerful static sensitive technique for the study of magnetic anisotropies and in...
particular provides an accurate value of the anisotropy field strength in the sample and a precise determination of the anisotropy axes.

2 Sample and experimental set up

Co$_2$MnSi thin films (20 and 50 nm in thickness) were deposited on a-plane sapphire substrate using vanadium seed underlayer by UHV-magnetron rf-sputtering using pure Ar at a pressure of 5×10$^{-3}$ mbar as sputter gas and at 470°C. After cooling them down to room temperature all the films were subsequently covered by a 5 nm thick gold layer protecting them against oxidation.

XRD measurements indicate that a <110>-type cubic axis is normal to the sample plane and the films behave as {110} fiber textures. The Co$_2$MnSi deduced cubic lattice constant (e.g.: a = 5.658 Å) is in good agreement with the previously published value (5.654 Å) [5].

The dynamic magnetic properties were studied using MS-FMR [6] setup piloted via a Labview program providing flexibility to real time control the magnetic field sweep direction, step and rate, real time data acquisition and visualization. This set-up which uses a vector network analyzer as generator allows measurements for both field and frequency sweeps. The resonance frequencies and fields are obtained from a fit assuming a lorentzian derivative shape of the recorded spectra. The obtained magnetic anisotropy parameters are compared to those determined from transverse biased initial inverse susceptibility and torque methods (TBIIST) [7]. In this technique, two magnetic fields $H_L$ and $H_B$ are applied in the plane of the film along directions defined by $\phi_L$ and $\phi_B+(\pm 2\pi)$, respectively, and the magnetization component $m_L$ is measured versus $H_L$ with a conventional magneto-optical Kerr experiment in longitudinal geometry. From the measured hysteresis loops, the initial inverse susceptibility ($\chi^{-1}$) and the field offset ($\Delta H$) which are related to the second and first angle-derivative of the magnetic anisotropy, respectively, are obtained. Fourier analysis then easily resolves various contributions of different symmetries to the magnetic anisotropy and gives precise values for anisotropy fields and their easy axes.

3 Magnetic properties

3.1 Static properties

For the 20 and 50 nm films, MOKE hysteresis loops were measured versus external magnetic field orientations with respect to the c-axis of the substrate. The corresponding angular dependence of coercive fields ($H_C$) and normalized remanent magnetizations ($M_r/M_s$) are represented on figure 1 for the 50 nm sample. The two samples have a similar angular dependence of $H_C$ and $M_r/M_s$ although the $H_C$ magnitude and the easy axes directions are different from each other. Apparently, the angular dependences agree with those of Stoner Wohlfarth (coherent rotation: CR) model. It is not straightforward to guess the anisotropy nature and deduce anisotropy fields from these measurements. Basing on the TBIIST measurements shown on figure 2, the anisotropy nature and fields have been deduced. As in [6], the experimental data of $M_r/M_s$ and $H_C$ have then been fitted considering a magnetic energy density which, in addition to Zeeman, demagnetizing and exchange terms, is characterized by the following anisotropy contribution:

$$E_{anis} = -\frac{1}{2} \left[ 1 + \cos(2(\phi_M - \phi_u)) \right] K_u \sin^2 M + K_2 \sin^2 M + \frac{1}{8} \left[ 3 + \cos(4(\phi_M - \phi_u)) \right] K_4 \sin^4 M$$

(1)

In the above expression, $\phi_u$ and $\phi_M$ respectively represent the out-of-plane and the in-plane (referring to the c-axis of the substrate) angles defining the direction of the magnetization $M$, $\phi_u$ and $\phi_M$ stand for the angles of the easy uniaxial and of the easy fourfold anisotropies (represented by their anisotropy constants $K_u$ and $K_4$ respectively) axes, respectively, with this c-axis. $K_u$ is the perpendicular uniaxial anisotropy.

![Fig. 1. (color online) Normalized remanent magnetization $M_r/M_s$ and coercive field $H_C$ of the 50 nm Co$_2$MnSi film.](image)

Despite of the perfect agreement for $M_r/M_s$, a significant discrepancy for $H_C$ is shown around the easy axis direction between the CR model and measurements. In fact, the coercive fields found in the magnetization loops around the easy axis are smaller than the one obtained from CR model since that they are usually determined by domain nucleation and sample imperfection. The best parameters used for the fit of TBIIST and MOKE measurements are summarized in table 1. The samples present a fourfold anisotropy superimposed to uniaxial anisotropy. In both films the c-axis of the substrate coincides with a principal direction of the fourfold magnetic anisotropy: it defines a hard axis ($\phi_L = 45^\circ$) for 20 nm in contrast to the 50 nm sample for which it defines an easy axis ($\phi_L = 0^\circ$). The directions of the principal axes of the twofold anisotropy are sample dependent. The observed variations of the in-plane magnetic anisotropy are not clearly related either to the thickness or to the crystallographic texture (which does not significantly change). During the preparation of the films uncontrolled parameters presumably induce different stress conditions giving rise to changes in the magnetic anisotropy.
The resonance condition is given by:

\[ F_g = \left( \frac{\gamma}{2\pi} \right)^2 \frac{1}{M_s^2 \sin^2 \theta_M} \left[ \frac{\partial^2 E}{\partial \theta_M^2} \frac{\partial^2 E}{\partial \phi_M^2} - \frac{\partial^2 E}{\partial \theta_M \partial \phi_M} \right]^2 \]  

(2)

The partial derivatives are evaluated at the equilibrium angles of the magnetization. We define

\[ M_{\text{eff}} = M_s - \frac{K}{2\pi M_s}, \quad H_u = \frac{2K_u}{M_s} \quad \text{and} \quad H_d = \frac{4K_d}{M_s} \]

as the effective magnetization, the in-plane uniaxial and the fourfold anisotropy fields respectively.

The MS-FMR technique, in perpendicular configuration, allows for deriving the values of \( g \) and of \( 4\pi M_{\text{eff}} \) from the variation of the resonance frequency versus the magnitude of the applied field. The MS-FMR field-dependences of the resonance frequencies of the uniform and of the perpendicular standing spin wave (PSSW: detectable only for 50 nm thick film) modes are shown on figure 3 for both samples. The frequencies vary linearly with \( H \). The derived value of \( g \), using the model presented in [6], is independent of the sample \( g = 2.04 \). The effective demagnetizing field \( 4\pi M_{\text{eff}} \) slightly increases versus the sample thickness but remains close to the saturation magnetization (12200 Oe) given by Hamrle [8]: it is reported in Table 1. The best fits for the observed PSSW are obtained using \( A_{ex} = 2.87 \mu\text{erg/cm} \).

The in-plane angular dependence of the resonance frequency (sweep frequency), resonance field (sweep field at different frequencies) and peak to peak field FMR linewidth (\( \Delta H^p \)) have been measured for each sample. The field angle with the c-axis has been varied from 0° to 360° by step of 10°. \( \Delta H^p \) has been taken as the separation in field between the extrema of the FMR derivative curves. The typical obtained results are represented on figure 4 for the 50 nm thick sample and compared to the best fit using the above mentioned model.

For all the samples, the obtained values of the magnetic parameters corresponding to the best fits reported in Table 1 are in good agreement with those obtained from the fit of the TBIIST measurements. The resonance field and frequency behavior is governed by a superposition of fourfold and uniaxial anisotropies having the c-axis of the substrate as an easy or hard axis. The difference and change in the fourfold anisotropy axes between the 20 and 50 nm thick samples are maybe due to the different local stress, sample process, growth condition and to the in-plane complex film structure. It was not possible to us to derive a quantitative understanding of the anisotropies resulting from the real film structure.

Table 1. Magnetic parameters obtained from the best fits to our experimental results using MS-FMR and TBIIST techniques. \( \varphi_u \) and \( \varphi_d \) are the angles of the in-plane uniaxial and of the fourfold anisotropy easy axes, respectively. \( \alpha_{app} \) is the apparent damping.

<table>
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<tr>
<th>Thickness (nm)</th>
<th>( A_{ex} ) (( \mu\text{erg/cm} ))</th>
<th>( M_{\text{eff}} ) (kOe)</th>
<th>( H_u = 2K_u/M_s ) (Oe)</th>
<th>( H_d = 4K_d/M_s ) (Oe)</th>
<th>( \varphi_u ) (deg.)</th>
<th>( \varphi_d ) (deg.)</th>
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Fig. 2. (color online) Inverse susceptibility (\( \chi' \)) and the field offset (\( \Delta H \)) of 50 nm Co2MnSi film. The measurements were obtained using transverse static bias field \( H_B = 125 \) Oe.

Fig. 3. (color online) Uniform precession and perpendicular standing spin waves (PSSW) modes frequencies versus the perpendicular applied magnetic field for 20 and 50 nm thick Co2MnSi films. The solid lines refer to the fit suing the above mentioned model.

Fig. 4. (color online) Angular dependence of the resonance frequency (\( F_g \)), resonance field (\( H_r \)) and peak to peak field FMR linewidth (\( \Delta H^p \)) for 50 nm thick Co2MnSi film. The solid lines refer to the fit suing the above mentioned model.

Figure 4c shows clear variations of \( \Delta H^p \) versus the applied field direction for 50 nm thick film. The frequency dependence of this linewidth for an applied field along the easy axis is represented on figure 5.
The experimental results were analyzed considering intrinsic and extrinsic mechanisms. The intrinsic contribution, which in our case has no angular dependence due to the fact that the applied fields and magnetization are parallel, traduces the apparent Gilbert damping. In order to describe the extrinsic contribution in the FMR linewidth, the most relevant mechanisms, such as two magnon scattering, mosaicity and inhomogeneities, have been taken into account. However, the large angular variation of $\Delta H^{PP}$ in our case cannot only be caused by mosaicity, which traduces variations in the internal fields, thickness, or orientation of crystallites within the sample. Dispersion of 1° of anisotropy axis, which in our opinion remains far from reality and obtained values in practice, gives $\Delta H^{PP}$ variations of 4 Oe at 8 GHz. Although two magnon scattering can gives rise to high variation of the angular dependence of linewidth in our case, it cannot perfectly reproduce its shape in our case (Fig. 4c). It is therefore more probably that other mechanisms like inhomogeneities, are responsible of such behavior of $\Delta H^{PP}$. Indeed, for some field orientations (around hard axis), the peak shows a complex shape suggesting that the measured FMR spectrum is a superposition of more than one peak maybe due to the complex in-plane structure of films revealed by XRD (not shown here).

Fig. 5. Frequency dependence of the peak to peak field FMR linewidth ($\Delta H^{PP}$) for 50 nm thick Co$_2$MnSi film. The solid lines refer to the fit using equation (3).

We thus tried to fit the variation of linewidth versus frequency using the expression (3):

$$\Delta H^{PP} = \frac{2}{\sqrt{3}} \frac{\alpha_{app}}{\gamma} f + \Delta H^{PP}(0)$$

(3)

$\Delta H^{PP}(0)$ describes linewidth arising from inhomogeneous broadening.

The obtained value of apparent damping $\alpha_{app}=0.0112$ for the 50 nm thick film (see table) lay in the range of the observed ones [9]. It is also in good agreement with that of the 20 nm thick film (see table) measured with an applied field perpendicular to the sample plane where two magnon scattering contribution vanishes.

Due to the high values of $4 M_{sat}$ for our samples, the frequency variation of $\Delta H^{PP}$ does not allow for evidencing the existence of the two magnon contribution in contrast to its in-plane angular dependence.

4 Conclusion

Co$_2$MnSi films of 20 nm and 50 nm in thicknesses were prepared by sputtering on a a-plane sapphire substrate. They show practically identical crystallographic textures, as revealed by our X-rays diffraction studies, with a cubic [110] axis normal to the film-plane and with a well defined manifold of in-plane orientations referring to the c-axis of the substrate. The micro-strip ferromagnetic resonance (MS-FMR), transverse biased initial inverse susceptibility and torque (TBIIST) methods have been used to study their dynamic and static properties. The in-plane anisotropy presents two contributions, showing a four-fold and a two-fold axial symmetry, respectively. A good agreement between parameters deduced from the fit of MS-FMR and TBIIST measurements has been obtained.

References